

CLAIMS:

1. A method of making an excimer laser crystal optic, said method comprising:
 - providing a magnesium fluoride crystal solid precursor
 - nonmetallically crushing said magnesium fluoride solid precursor to provide a crushed low metal contaminant magnesium fluoride feedstock,
 - providing a c axis oriented magnesium fluoride seed crystal,
 - providing a magnesium fluoride crystal growth crucible, said crystal growth crucible having a seed crystal reservoir for receiving an oriented seed crystal,
 - inserting said c axis oriented magnesium fluoride seed crystal into said crystal growth crucible seed crystal reservoir,
 - loading said crushed magnesium fluoride feedstock into said crystal growth crucible,
 - melting said loaded crushed magnesium fluoride feedstock to provide a precrystalline magnesium fluoride melt,
 - growing a c axis oriented magnesium fluoride crystal from said precrystalline magnesium fluoride melt,
 - cooling said grown magnesium fluoride crystal to provide a magnesium fluoride laser crystal with a 42 mm crystal 120 nm transmission of at least 30%,
 - and forming said magnesium fluoride laser crystal into an excimer laser crystal optic.
2. A method as claimed in claim 1, wherein providing a magnesium fluoride crystal solid precursor includes providing a purified magnesium fluoride crystal solid precursor.
3. A method as claimed in claim 1, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container while crushing.
4. A method as claimed in claim 1, wherein nonmetallically crushing said magnesium fluoride solid precursor includes providing a nonmetallic crusher.

5. A method as claimed in claim 1, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container and applying a nonmetallic crushing force to said solid precursor through said flexible nonmetallic container.

6. A method as claimed in claim 1, said method including providing a contaminant scavenger and scavenging contaminants from said magnesium fluoride.

7. A method as claimed in claim 1, wherein melting said crushed magnesium fluoride feedstock to providing a precrystalline magnesium fluoride melt includes melting no more than 90% of said c axis oriented magnesium fluoride seed crystal.

8. A method as claimed in claim 1, wherein growing a magnesium fluoride crystal includes lowering said crystal growth crucible through a magnesium fluoride crystal growth temperature gradient at a rate no greater than 1 mm per hour.

9. A method as claimed in claim 1, wherein forming said magnesium fluoride laser crystal into an excimer laser crystal optic includes forming said laser crystal into a magnesium fluoride crystal optic window.

10. A method as claimed in claim 1, wherein forming said magnesium fluoride laser crystal into an excimer laser crystal optic includes forming said laser crystal into a magnesium fluoride crystal optic prism.

11. A method as claimed in claim 1, wherein said crushed low metal contaminant magnesium fluoride feedstock has metal contaminant levels less than 1 ppm by weight.

12. A method as claimed in claim 1, wherein said crushed low metal contaminant magnesium fluoride feedstock has transition element metal contaminant levels no greater than .7 ppm by weight.

13. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a Fe contamination level less than .15ppm Fe by weight.

14. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a chrome contamination level less than .06ppm chrome by weight

15. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a copper contamination level less than .02ppm copper by weight

16. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a cobalt contamination level less than .02ppm cobalt by weight

17. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has an Al contamination level less than .7ppm Al by weight

18. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a nickel contamination level less than .02ppm nickel by weight.

19. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a vanadium contamination level less than .02ppm vanadium by weight.

20. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a lead contamination level less than .02ppm lead by weight.

21. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a molybdenum contamination level less than .02ppm molybdenum by weight.

22. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a manganese contamination level less than .02ppm manganese by weight.

23. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a 42mm crystal 120nm transmission of at least 35%.

24. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has a 255nm induced absorption less than .08 Abs/42mm when exposed to 5 million pulses of 193nm light at a fluence $\geq 40\text{mJ/cm}^2/\text{pulse}$.

25. A method as claimed in claim 1, wherein said magnesium fluoride laser crystal has an 200 to 210 nm range absorption coefficient $< 0.0017\text{ cm}^{-1}$.

26. A method of making a magnesium fluoride optical crystal, said method comprising:

- providing a magnesium fluoride crystal solid precursor,
- nonmetallically crushing said magnesium fluoride solid precursor to provide a crushed low metal contaminant magnesium fluoride feedstock,
- providing a magnesium fluoride crystal growth crucible,
- loading said crushed magnesium fluoride feedstock into said crystal growth crucible,
- melting said loaded crushed magnesium fluoride feedstock to provide a precrystalline magnesium fluoride melt,
- growing a magnesium fluoride crystal from said precrystalline magnesium fluoride melt,
- cooling said grown magnesium fluoride crystal to provide a magnesium fluoride optical crystal.

27. A method as claimed in claim 26, wherein providing a magnesium fluoride crystal solid precursor includes providing a purified magnesium fluoride crystal solid precursor.

28. A method as claimed in claim 26, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container while crushing.

29. A method as claimed in claim 26, wherein nonmetallically crushing said magnesium fluoride solid precursor includes providing a nonmetallic crusher.

30. A method as claimed in claim 26, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container and applying a nonmetallic crushing force to said solid precursor through said flexible nonmetallic container.

31. A method as claimed in claim 26, wherein said crushed low metal contaminant magnesium fluoride feedstock has metal contaminant levels less than 1 ppm by weight.

32. A method as claimed in claim 26, wherein said crushed low metal contaminant magnesium fluoride feedstock has transition element metal contaminant levels no greater than .7 ppm by weight.

33. A method as claimed in claim 26, wherein said a magnesium fluoride optical crystal has a Fe contamination level less than .15ppm Fe by weight.

34. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a chrome contamination level less than .06ppm chrome by weight

35. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a copper contamination level less than .02ppm copper by weight

36. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a cobalt contamination level less than .02ppm cobalt by weight

37. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has an Al contamination level less than .7ppm Al by weight

38. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a nickel contamination level less than .02ppm nickel by weight.

39. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a vanadium contamination level less than .02ppm vanadium by weight.

40. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a lead contamination level less than .02ppm lead by weight.

41. A method as claimed in claim 26, wherein said magnesium fluoride crystal has a molybdenum contamination level less than .02ppm molybdenum by weight.

42. A method as claimed in claim 26, wherein said magnesium fluoride crystal has a manganese contamination level less than .02ppm manganese by weight.

43. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a 120nm transmission of at least 30%.

44. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has a 255nm induced absorption less than .08 Abs/42mm when exposed to 5 million pulses of 193nm light at a fluence $\geq 40\text{mj}/\text{cm}^2/\text{pulse}$.

45. A method as claimed in claim 26, wherein said magnesium fluoride optical crystal has an 200 to 210 nm range absorption coefficient $< 0.0017 \text{ cm}^{-1}$.

46. A method of making an optical fluoride crystal, said method comprising:
providing a fluoride crystal solid precursor,
nonmetallically crushing said fluoride solid precursor to provide a crushed low metal contaminant fluoride crystal feedstock,

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providing a fluoride crystal growth crucible,
loading said crushed fluoride crystal feedstock into said crystal growth
crucible,
melting said loaded crushed fluoride crystal feedstock to provide a
precrystalline fluoride melt,
growing a fluoride crystal from said precrystalline fluoride melt,
cooling said grown fluoride crystal to provide an optical fluoride crystal.

47. A method as claimed in claim 46, wherein providing a fluoride crystal solid precursor includes providing a purified fluoride crystal solid precursor.

48. A method as claimed in claim 46, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container while crushing.

49. A method as claimed in claim 46, wherein nonmetallically crushing said magnesium fluoride solid precursor includes providing a nonmetallic crusher.

50. A method as claimed in claim 46, wherein nonmetallically crushing said magnesium fluoride solid precursor includes containing said magnesium fluoride within a flexible nonmetallic container and applying a nonmetallic crushing force to said solid precursor through said flexible nonmetallic container.

51. A method as claimed in claim 46, wherein said crushed low metal contaminant magnesium fluoride feedstock has metal contaminant levels less than 1 ppm by weight.

52. A method as claimed in claim 46, wherein said crushed low metal contaminant magnesium fluoride feedstock has transition element metal contaminant levels no greater than .7 ppm by weight.

53. A method as claimed in claim 46, wherein said optical fluoride crystal has a 120nm transmission of at least 30%.

54. A method as claimed in claim 46, wherein said optical fluoride crystal has a 255nm induced absorption less than .08 Abs/42mm when exposed to 5 million pulses of 193nm light at a fluence $\geq 40\text{mJ/cm}^2/\text{pulse}$.

55. A method as claimed in claim 46, wherein said optical fluoride crystal has a 200 to 210 nm range absorption coefficient $< 0.0017 \text{ cm}^{-1}$.